


<b>Search Notes</b>  	<b>Application/Control No.</b>  10677112	<b>Applicant(s)/Patent Under Reexamination</b>  HOFMANN ET AL.
	<b>Examiner</b>  Liu, Lin	<b>Art Unit</b>  2145

<b>SEARCHED</b>			
<b>Class</b>	<b>Subclass</b>	<b>Date</b>	<b>Examiner</b>
709	237	06/08/2007.	LL

<b>SEARCH NOTES</b>		
<b>Search Notes</b>	<b>Date</b>	<b>Examiner</b>
Text search of USPAT, USPGPUB, EPO, JPO, DERWENT, IBM_TDB, see search history printout.	06/08/2007	L.L
Limited classified search of 709/232, 236, 237	06/14/2007	L.L
L1: 709/237.ccls. and (@ad<20021213) reviewed consicely	06/08/2007	L.L
709/237.ccls. not L1, reviewed cursory.	06/08/2007	L.L
Diaglog search attached	06/15/2007	L.L

<b>INTERFERENCE SEARCH</b>			
<b>Class</b>	<b>Subclass</b>	<b>Date</b>	<b>Examiner</b>